## **AMENDMENTS TO THE CLAIMS**

- 1. (Currently Amended) A conductive plastic resistance element <u>for a variable resistor</u> having particles of conductive material <u>no larger than about 6 microns</u> embedded therein and projecting therefrom for <u>sliding</u> contact <u>by with</u> the wiper <u>contact</u> of <u>a potentiometric device in which the resistance element is employed the variable resistor</u>.
- 2. (Original) The resistance element of Claim 1 wherein the conductive material is silver.
- 3. (Original) The resistance element of Claim 1 wherein the conductive material is silver and palladium.
- 4. (Original) The resistance element of Claim 1 wherein the conductive material is selected from the group consisting of silver, palladium, gold, platinum, copper, highly conductive carbon, and combinations thereof.
- 5. (Currently Amended) The resistance element of Claim 1 wherein the conductive material is present in an amount equal to about 10 to 20 percent by weight of the resistive element.
- 6. (Currently Amended) The resistance element of Claim 1 wherein the conductive material is present in an amount equal to about 2 to 50 percent by weight of the resistive element.
- 7. (Original) A resistance element for use in a potentiometric device having a wiper contact which engages the resistance element, comprising a carbon/plastic matrix with conductive phases for reducing variations in resistance between the wiper contact and the resistance element over the life of the device.
- 8. (Original) The resistance element of Claim 7 wherein the conductive phases consist of silver.
- 9. (Original) The resistance element of Claim 7 wherein the conductive phases consist of silver and palladium.

- 10. (Original) The resistance element of Claim 7 wherein the conductive phases are selected from the group consisting of silver, palladium, gold, platinum, copper, highly conductive carbon, and combinations thereof.
- 11. (Currently Amended) The resistance element of Claim 7 wherein the conductive phases are present in an amount equal to about 10 to 20 percent by weight of the resistive element.
- 12. (Currently Amended) The resistance element of Claim 7 wherein the conductive phases are present in an amount equal to about 2 to 50 percent by weight of the resistive element.
- 13. (Withdrawn) A method of manufacturing a conductive resistance element for use in a potentiometric device, comprising the steps of: processing carbon powder, resin, solvent and conductive phases to form a paste, applying the paste to a substrate, and curing the paste to drive off the solvent and form a film, with the conductive phases rising to the surface of the film and becoming embedded therein.

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- 14. (Withdrawn) The method of Claim 13 wherein the paste is cured at a temperature on the order of 200°C.
- 15. (Withdrawn) The method of Claim 13 wherein the paste is screen printed onto the substrate.
- 16. (Withdrawn) The method of Claim 13 wherein the carbon powder, resin, solvent and conductive phases are processed in a high shear mixer.